

INTEGRATED MEMORY HAVING REDUNDANT UNITS OF MEMORY CELLS AND METHOD FOR TESTING AN INTEGRATED MEMORY

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CROSS REFERENCE TO RELATED APPLICATIONS

This application claims priority under 35 USC §119 to German Application No. 10311373.8, filed on March 14, 2003, and titled “Integrated Memory Having Redundant Units of Memory Cells and Method for Testing an Integrated Memory,” the entire contents of which are hereby incorporated by reference.

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FIELD OF THE INVENTION

The present invention relates to an integrated memory having memory cells in a memory cell array, and more particularly, to an integrated memory having memory cells combined to form individually addressable normal units and redundant units of memory 15 cells for respectively replacing one of the normal units on an address basis. The invention also relates to a method for testing an integrated memory of this type.

BACKGROUND

For the purpose of repairing faulty memory cells, integrated memories generally 20 have redundant units of memory cells which can replace normal units of memory cells containing faulty memory cells on an address basis. The redundant units of memory cells are, for example, in the form of redundant word lines or redundant bit lines which can replace normal word lines or normal bit lines. In this context, the integrated memory is tested using an external testing device or a self-test device, for example, and the 25 redundant elements are then programmed. A redundancy circuit has programmable

elements, for example, in the form of laser fuses or electrically programmable fuses, which are used to store the address of a unit which needs to be replaced. These programmable elements are programmed by means of a laser beam or by a “burning voltage”, for example, in the course of the memory’s production process.

5 During operation of a memory of this type, faulty normal units, which need to be replaced, are replaced on an address basis by appropriate redundant units in the course of a memory access operation. Before a memory access operation, a redundancy evaluation is made in the redundancy circuits within a selected memory area. This is done by applying an address for the selected normal unit to an address bus and then comparing the
10 applied address with an address for a faulty normal unit, which is stored in the respective redundancy circuit. If there is a match, the appropriate redundancy circuit activates the associated redundant unit instead of the faulty normal unit.

Integrated memories are generally subject to extensive function tests in the production process. These function tests are used, *inter alia*, to identify faulty memory
15 cells or faulty word lines or bit lines. Function tests are also carried out on memories which have already been used in the application and in which faults have been found during operation of the memory. In such cases, it is desirable to carry out fault analysis in order to be able to gain further knowledge of physical relationships and failure probabilities.

20 One cause of varying fault behavior resides, for example, in the fact that the “data background” of certain memory cells differs depending on the memory. Faulty memory cells may, in particular, be physically adjacent to redundant units. In this case, a factor influencing the fault behavior of the memory cells in the immediate vicinity of redundant

elements is whether one or more of the adjacent redundant elements are being used, i.e., have been programmed for a replacement operation for normal units (and thus have been topologically defined). Information of this type has hitherto not been available when analyzing a closed memory chip which has already been used in the application, since the 5 original fault analysis data which was obtained by function tests in the production process is no longer available. In order, nevertheless, to make it possible to analyze the topology sensitivity of a fault mechanism, complicated preparation involving opening of the memory chip package is necessary. Preparation of this type entails the risk of the chip possibly being destroyed and as a result no longer being available for further analysis.

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SUMMARY

Providing an integrated memory in which it is possible to analyze the topology sensitivity of a fault mechanism in a function test without the chip having to be prepared and opened for this purpose is desirable.

15 A method (which is suitable for this purpose) for testing such a memory is also desirable.

An integrated memory in accordance with the invention can include, in addition to normal and redundant units of memory cells, a memory unit for storing, in a normal mode, an address for one of the normal units which needs to be replaced by one of the 20 redundant units. The integrated memory can also include a comparison unit which is connected to an address bus in the memory and to an output of the memory unit. The comparison unit can compare an address which is present on the address bus with an address stored in the memory unit. In the event of a match being identified, it can

activate an appropriate redundant unit. The memory in accordance with the invention also has a test circuit which can be activated by a test mode signal and can be used to reset the memory unit to an initial state and to store an address for one of the redundant units in the memory unit for the purpose of subsequently writing to this redundant unit.

5 In a test method for the purpose of analyzing the topology sensitivity of a fault mechanism, first a test mode can be activated by activating the test mode signal. The memory unit can be reset to an initial state by the test circuit. An address for one of the redundant units can subsequently be stored in the memory unit and an identification code can be written to this redundant unit. The test mode can then be deactivated and the

10 memory unit can be set using the “postfuse” information, i.e., using the address for one of the normal units which needs to be replaced. The memory cell array can then be accessed by applying addresses for normal units to the address bus so that the memory cell array can be read. Reading the memory cell array can involve a replacement operation being executed upon application of the address for that normal unit, which needs to be replaced

15 by the redundant unit to which the identification code has previously been written.

 The identification code, which is read in the process, can be associated with the address for the normal unit addressed for this purpose, which has been replaced by the redundant unit to which the identification code was written. Now it is possible to analyze which normal unit is replaced by which redundant unit, i.e., which redundant unit is

20 associated with which normal unit. Thus, the topology sensitivity of a fault mechanism can be analyzed without requiring complicated preparation involving opening of the chip package.

BRIEF DESCRIPTION OF THE DRAWINGS

The invention is explained in more detail below with reference to FIGS. 1A and 1B, which illustrate an exemplary embodiment of the present invention.

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DETAILED DESCRIPTION

FIGS. 1A and 1B show one exemplary embodiment of an inventive integrated memory which has memory cells MC, RMC in a memory cell array 1 having word lines WL, redundant word lines RWL and bit lines BL. The memory cells MC can be arranged at crossover points between the bit lines BL and word lines WL. The redundant memory cells RMC can be arranged at crossover points between the bit lines BL and redundant word lines RWL. To assist understanding, FIGS. 1A and 1B are used to explain the invention only with regard to a few redundant word lines RWL. In practice, an integrated memory generally can include a plurality of redundant lines. The invention may also be applied to redundant bit lines or redundant memory blocks in the memory. The invention 10 relates to any desired types of integrated memories in which redundant addressable units with memory cells are used to replace normal addressed units of memory cells. The invention 15 relates to any desired types of integrated memories in which redundant addressable units with memory cells are used to replace normal addressed units of memory cells.

The exemplary embodiment shown in FIGS. 1A and 1B is a DRAM. The memory cells MC, RMC of the DRAM each can include a selection transistor and a storage capacitor. In this case, control inputs of the selection transistors can be connected 20 to one of the word lines WL, RWL, while a main current path in the selection transistors can be arranged between the storage capacitor in the respective memory cell MC, RMC and one of the bit lines BL.

The memory can also have a programmable memory unit 2 for storing an address for a word line WL which needs to be replaced. The memory unit 2 can be, for example, a register having register elements for storing a respective address bit. There can also be a second nonvolatile memory unit 4, which can be programmed once and can have laser fuses which can be programmed, for example, from outside the memory by means of a laser beam. The memory unit 4 can be used to permanently store an address for a word line WL which needs to be replaced, and can have an output 41 which is connected to a corresponding input 21 of the memory unit 2 for the purpose of transmitting an address stored in the memory unit 4 to the memory unit 2.

10 There can also be a comparison unit 3, which can be connected to an address bus 7 in the memory and to an output 22 of the memory unit 2. The comparison unit 3 can compare the address stored in the memory unit 2 with the current address ADR present on the address bus 7. If the current address is found to match the address stored in the memory unit 2, the comparison unit 3 can activate one of the redundant word lines RWL 15 and can use a deactivation signal /EN to deactivate a word line WL, which is addressed by the current address ADR. A word line decoder 6 can be connected to the address bus 7 and, in the active state, can activate one of the word lines WL, RWL, which is associated with the corresponding address. If, however, a redundant word line RWL has been addressed, it is necessary to prevent activation of a normal word line WL, which 20 needs to be replaced. This can be ensured by the comparison unit 3 by the deactivation signal /EN.

The address stored in the nonvolatile memory unit 4 can be loaded into the programmable memory unit 2, for example, when the memory chip is “powered up”. The

address stored in the memory unit 2 then represents the position of the normal word line WL which needs to be replaced, and not the position of the associated redundant word line RWL. Direct association (which can be detected from outside) between the word line WL, which needs to be replaced and the associated redundant word line RWL is not 5 possible.

The memory can also have a test circuit 5, which can be activated by a test mode signal TM and can make it possible to reset the memory unit 2 to an initial state (“prefuse settings”). When resetting the memory unit 2, an address for one of the redundant word lines RWL can be stored in the memory unit 2 for the purpose of subsequently writing to 10 this redundant word line. For example, the address 105 for a redundant word line RWL can be stored in the memory unit 2. This redundant word line can then be accessed, and an identification code, for example, the value 105, can be written to the redundant word line. In this case, the address stored in the memory unit 2 represents the position of the redundant word line. The test mode signal TM and thus the corresponding test mode can 15 then be deactivated.

As was previously the case when the memory was powered up, the memory unit 2 can then be set using the address for a normal word line WL, which needs to be replaced (postfuse setting). The memory cell array 1 can subsequently be accessed, and the addresses for the normal word lines WL can be successively applied in order to read the 20 memory cell array 1. The memory unit 2 can, for example, be set using the address 25 for a normal word line WL which needs to be replaced. If, when the memory cell array 1 is being read, the word line WL having the address 25 is accessed, it can be replaced on an address basis by the redundant word line RWL having the address 105. To this end,

the comparison unit 3 can ascertain that the address 25 present on the address bus 7 matches the address stored in the memory unit 2, whereupon the redundant word line RWL having the address 105 can be activated. In this case, the identification code 105 stored therein can be read and may be associated with the address 25 for the normal word line WL addressed via the address bus 7. This results in the redundant word line RWL with the address 105 being associated with the normal word line WL having the address 25.

The invention thus makes it possible to ascertain which redundant element is associated with which normal element which needs to be replaced. This means that it is also possible to analyze the topology sensitivity of a fault mechanism at a later stage in which test results of function tests in the course of a memory's production process are no longer available. To this end, it is possible to dispense with complicated preparation involving opening of the chip package.

While the invention has been described in detail and with reference to specific embodiments thereof, it will be apparent to one skilled in the art that various changes and modifications can be made therein without departing from the spirit and scope thereof. Accordingly, it is intended that the present invention covers the modifications and variations of this invention provided they come within the scope of the appended claims and their equivalents.

LIST OF REFERENCE SYMBOLS

1		Memory cell array
2		Memory unit
5	3	Comparison unit
4		Memory unit
5		Test circuit
6		Word line decoder
7		Address bus
10	21	Input
	22	Output
	41	Output
	WL	Word lines
	RWL	Redundant word lines
15	BL	Bit lines
	MC	Memory cells
	RMC	Redundant memory cells
	ADR	Address
	/EN	Deactivation signal
20	TM	Test mode signal